

3/13/06

U.S. Department of Commerce, Patent and Trademark		Atty. Docket No.		Application No.	
INFORMATION DISCLOSURE STATEMENT BY APPLICANT		SNDK.352US0		10/799,060	
(Use several sheets if necessary)		Applicant(s)		Conf. No.	
(Form PTO-1449)		Jeffrey W. LUTZE et al.		6740	
10/2		Filing Date		Art Group	
		March 12, 2004		2818	

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*Examiner Initial		Document Number	Date	Name	Class	Subclass	Filing Date If Appropriate
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	9	6,417,051 B1	07-2002	Takebuchi			
	10	6,461,973	10-2002	Hui et al.			
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	21	6,838,357 B2	01-2005	Chen et al.			
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Examiner Dle Date Considered 6/2006

*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with your communication to applicant.

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		Document	Date	Country	Class	Subclass	Yes	No

OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)		
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Foreign Patent Documents								
							Translation	
		Document	Date	Country	Class	Subclass	Yes	No
Dle	7	EP 1274132 ✓	01/2003	EPO			✓	
	8	EP 1363324 ✓	11/2003	EPO			✓	

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